

1-1, Samsungjeonja-ro, Hwaseong, Rep. of KOREA

## **Research Interests**

Device Circuit Modeling, Physical Electronics, Photonics Integrated Circuits, Analog/Digital Integrated Circuits

Work Experience

SPICE GROUP, SAMSUNG FOUNDRY

Samsung Electronics. Co., Ltd.

Hwaseong, S.Korea

Feb. 2018 - Present

**Project Experience** 

MBCFET(Multi-Bridge-Channel FET) SPICE Modeling

3GAE PROCESS SPICE DEVELOPER

Samsung Foundry Oct. 2018 - Oct.2019

- Device behavior analysis and Process Design Kit structure development
- Implemented Characteristics of threshold voltage, Saturation & Linear Current

**FinFET SPICE Modeling** 

Samsung Foundry

7NM PROCESS SPICE DEVELOPER

Oct. 2018 - Dec. 2019

- FinFET Layout Structure analysis
- Implemented Characteristics of threshold voltage, Saturation & Linear Current

FDSOI(Fully Depleted Silicon-On-Insulator) SPICE Modeling

LN18FDSOI, LN28FDSOI SPICE DEVELOPER

Samsung Foundry Oct. 2019 - Present

- pre &post simulation on circuit designer's view
- Implemented Characteristics of threshold voltage, Saturation & Linear Current

**Silicon Data Mining Tool Development** 

Mar. 2020 - Oct.2021

- TOOL DEVELOPER
- Integrated silicon handling method SPICE team, Device team and Fab
- Integrated HSPICE, Tcl, Perl, Python Code
- Awarded Samsung Foundry Work Smart Fair 2021.Q2

**Samsung Unified Infra Structure Development** Samsung Foundry

TOOL DEVELOPER

- Standardized SPICE model library structure
- Encapsulation of HSPICE, Python, Verilog-A, Perl
- Awarded Design Platform Team Project

**PMIC SPICE Modeling** Samsung Foundry

BCD1370, BCD1340HP, APM906M, BCD90GP SPICE DEVELOPER

Oct. 2018 - Present

Mar. 2019 - Mar. 2020

- Developed schottky diode, zener diode, iso-bjt, resistor, varactor
- Reformed model equation, library structure, TEG structure

**CMOS Image Sensor SPICE Modeling** 

LF6/LF6S SPICE DEVELOPER

Samsung Foundry Oct. 2018 - Present

• Implemented Characteristics of threshold voltage, Saturation & Linear Current

Reformed model equation, library structure, TEG structure

Samsung Foundry Oct. 2018 - Present

Pannel & Mobile DDI SPICE Modeling LL1313GP, LL1318GPS, LL13A13P SPICE DEVELOPER

• Implemented Characteristics of threshold voltage, Saturation & Linear Current

· Reformed model equation, library structure, TEG structure

Samsung Foundry

Oct.2020

**MOS Varactor Model Equation Development** 

• Published Samsung Foundry Symposium

• Increased Performance by 3x, Reduced Memory usage by 20%

OCTOBER 17, 2022

THE 2ND AUTHOR

CHANG SEOB LEE · CURRICULUM VITAE

#### SKKU(SungKyunKwan University)

Suwon, S.Korea

**B.S. IN SEMICONDUCTOR SYSTEMS ENGINEERING** 

Mar. 2012 - Feb. 2018

• Relevant Courses: Analog IC Design, Digital IC Design, Semiconductor Integration Engineering, Physical Electronics, Display Device and Process, Electromagnetism, Probability Random Process, Honor Calculus

# **Scholarships & Awards**

2021. Jun Individual Award, Samsung Foundry Work Smart Fair 2021. Q2 2020.Mar Project Award, Developed Samsung Unified Modeling Infra Structure

Samsung Foundry

2012-2017 Samsung Rental Scholarship, which is given to promising students (7 Semesters)

B.S in SKKU

Samsung Foundry

2012-2017 Samsung Semiconductor Scholarship, which is given to promising students (6 Semesters)

B.S in SKKU

## **Hosted Seminars**

### **Deembedding Methodology**

Samsung Foundry

TO ST MICRONICS, FRANCE

Aug.2022-Oct.2022

How to de-embed Metal. Contact Access Effect in SOI Process

#### **HSPICE Optimizer Algorithm**

Samsung Foundry

TO SAMSUNG FOUNDRY

Sep.2022

· Levenberg-Marquardt algorithm, Combination of Steepest Decent method and the Gauss-Newton method

### Ridge Regression, Linear Algebra

Samsung Foundry

TO SAMSUNG FOUNDRY

Apr.2022

· Geometric, statistical interpretation of Ridge Regression and how to apply in SPICE Model

#### **SPICE Modeling Methodology**

Samsung Foundry

TO SSIR(SAMGSUNG SEMICONDUCTOR INDIA RESEARCH), INDIA

Jun.2019

· Library Structure, usage of internal SPICE modeling tools

#### **Photo Diode Model Implement Methodology**

Samsung Foundry

TO SAMSUNG FOUNDRY

Jun.2019

• Build model equation, model & Silicon correlation Verification, Netlist Library

# Field Training in Samsung Electronics

2022.Sep Digital Integrated Circuit Design (40hr), Memory, Multiplier&Shifter, Adder, Desgin methodology, Timing

2021.Oct Regression Analysis (36hr), Model Validation and Diagnostics, Ridge&LASSO Regression, Projection

2021.Sep Mathematical Statistics (24 hr), Method of Estimation, Confidence Interval, Normal Distribution

2021. Nov Structured Big Data Analysis (32hr), Ensemble Algorithms, Linear Regression

2020.Jun Python (32 hr), scikit-learn (K-Nearest Neighbor, Decision Tree, PCA, mRMR, DTW)

2019.Mar Machine Learning (32 hr), Dimension Reduction Algorithm, Support Vector Machine

2019. Jun FinFET Layout (32hr), Layout drawing, LVS & DRC verification

2018.Aug Process Design Kit (12hr), Connection of SPICE, PEX, CDS, DRC, LVS Teams

2018. Jun Analog Integrated Circuit Design (32hr), OP-Amplifier Circuits, Output Stages and Power Amplifiers

2018. Jun Device/Process (64hr), Advanced transistor, Future Devices

# Skills

**Programming** Python, Perl, Git, Verilog-A, C/C++, Matlab, LINUX, Excel VBA, Tcl

**Tools** HSPICE, Spectre, BSIMProPlus, IC-CAP, Cadence tools, Spotfire